

Docket No: 42P15995

Patent

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of:

Haubensak

Application No.: 10/674,372

Filing Date: September 29, 2003

For: WAFER DEFECT REDUCTION
BY SHORT PULSE LASER
ABLATION

) Examiner: Elve, Maria Alexandria

) Art Unit: 3742

) Confirmation No. 5201

Commissioner for Patents
P.O. Box 1450
Alexandria, Virginia 22313-1450

RESPONSE TO OFFICE ACTION

Sir:

In response to the Office Action mailed January 6, 2009, applicant respectfully requests the Examiner to enter the following amendments and consider the following remarks.

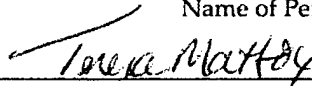
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April 3, 2009

Date